

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE



K-1968

Applicant : Yasumi Sago et al

Title : PLAXMA-ENHANCED PROCESSING APPARATUS

Serial No. : 09/809,274

Filed : March 16, 2001

Group Art Unit : 1763

Examiner : Luz L. Alejandro

Hon. Commissioner of Patents and Trademarks  
Washington, D. C. 20231

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# 7  
7/16 '02  
MW

July 5, 2002

AMENDMENT

Sir:

In response to the restriction requirement of June 7, 2002, please amend application as follows:

IN THE CLAIMS

Please amend claims 7 and 10, as follows:

7. (Twice amended) A plasma-enhanced processing apparatus as claimed in claim 6, wherein;

C1 said front board is made of silicon poly-crystal or silicon mono-crystal.

S2 10. (Twice amended) A plasma-enhanced processing apparatus as claimed in claim 6, wherein;

C2